



AMEN	Docket No. FIS920030091US1					
Applicatio		Filing Date		Examiner		Art Unit
10/604,	146	06/27/03		Jack S. J. Ch	en	2813
pplicant(s): Joe	METHOD OF	MAKING A B	URIED OXID	DE LAYER USING B	ASE IMP	LANT AND
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x charge a	ıny additional fili	ng or applicatio	n processing (fees required under 3	7 CFR 1.1	6 and 1.17.
Daryl K. Neff Attorney Reg. N	No.: 38,258	ff.		Dated:	May 9, 2	2005
I hereby certify that this sufficient postage as Fi Alexandria, VA 22313- Dated: May 9, 2005	irst Class Mail, in an	n envelope address shown below.	ansmitted to the U	USPTO or deposited with the depent, Commissioner for P	e U.S. Postal atents, P.O. f	Service with Box 1450,

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Name of Depositor: Daryl K. Neff Signature

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE				
In re application of: Joel P. DeSouza et al.	Date: May 9, 2005			
Serial Number: 10/604,146	Examiner: Jack S. J. Chen			
Filed: June 27, 2003	Group Art Unit: 2813			
Title: SIMOX METHOD OF MAKING A BURIED OXIDE LAYER USING BASE IMPLANT AND ROOM TEMPERATURE IMPLANT(Amended)	H. Daniel Schnurmann IBM Corporation Dept. 18G, B/321, Zip 482 2070 Route 52 Hopewell Junction, NY 12533			

AMENDMENT

MS Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated February 8, 2005, Applicants submit the following amendments and remarks for the Examiner's consideration.

Title of the Invention

Please amend the Title to read:

SIMOX METHOD OF MAKING A BURIED OXIDE LAYER USING BASE IMPLANT AND ROOM TEMPERATURE IMPLANT